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Femtosecond-irradiation-induced refractive-index changes and channel waveguiding in bulk Ti³⁺: Sapphire

V. Apostolopoulos,^{a)} L. Laversenne, T. Colomb, C. Depeursinge, R. P. Salathé, and M. Pollnau

Advanced Photonics Laboratory, Institute for Imaging and Applied Optics, Swiss Federal Institute of Technology, CH-1015 Lausanne, Switzerland

R. Osellame, G. Cerullo, and P. Laporta

Dipartimento di Fisica, Politecnico di Milano and IFN-CNR, Piazza Leonardo da Vinci 32, I-20133 Milano, Italy

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We have employed femtosecond laser writing in order to induce refractive-index changes and waveguides in Ti^{3+} -doped sapphire. Doping the sapphire crystal with an appropriate ion significantly reduces the threshold for creating structural changes, thus enabling the writing of waveguide structures. Passive and active buried channel waveguiding is demonstrated and images of the guided modes, propagation-loss values, fluorescence spectra, and output efficiencies are presented. The guiding area is located around the laser-damaged region, indicating that the guiding effect is stress induced. Refractive-index changes are measured by digital holography. Proper active doping should enable femtosecond processing and waveguide writing in various crystalline materials. © 2004 American Institute of Physics. [DOI: 10.1063/1.1781737]